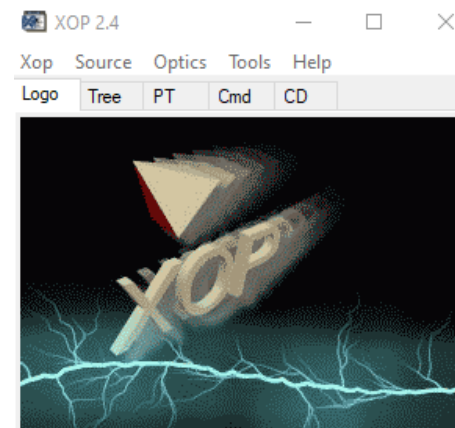


# XOP – OVERVIEW



**ROGER DEJUS**  
Control Account Manager for  
Insertion Devices for APS Upgrade

# Outline

- History and Scope
- Overview
- Examples
- Current distribution (v2.4)
- Summary

## History and Scope

- Developed during the early 1990s to suit local needs at the ESRF and the APS (efforts officially merged 1995; now 25 years in the making)
- XOP v2.0: 1,000 CD-ROMs distributed (400 registered users)
- Front-end graphical user interface (written in the Interactive Data Language IDL) for computer codes (of different origins and different languages) for the synchrotron radiation community
  - Modelling of x-ray sources
  - Characterization of optical elements (mirrors, filters, crystals, multilayers, etc.)
  - Multipurpose visualizations and data analyses
  - Optional plug-in of external software packages “extensions” expanding the functionality of XOP

## X-Ray Sources

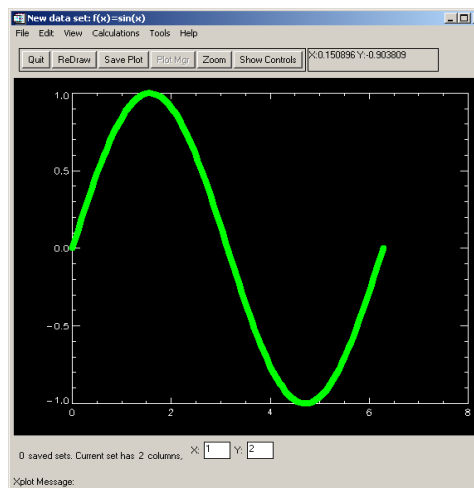
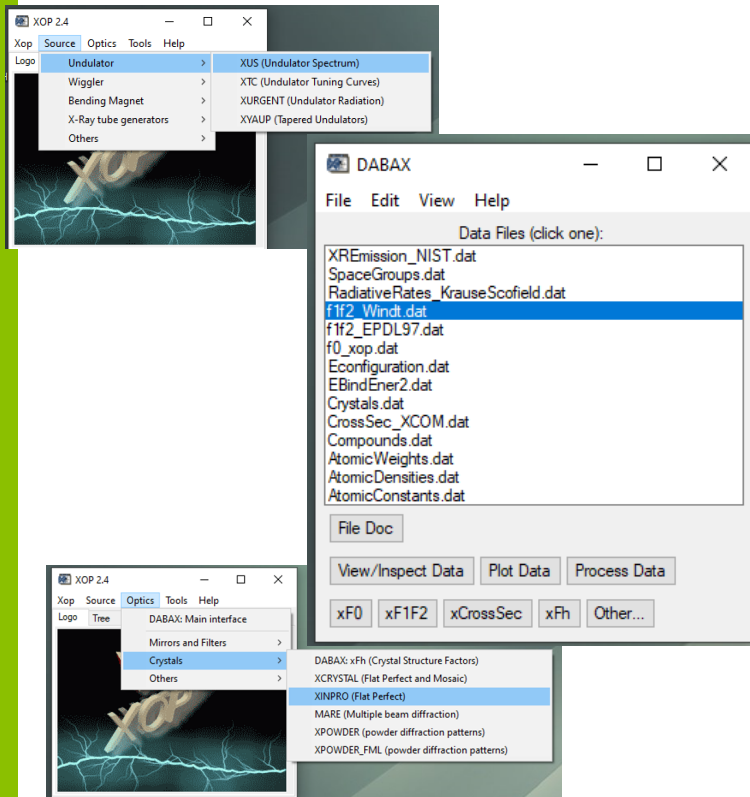
## X-Ray Optics and Photon Atom Interactions

## Overview

## General Purpose Tools and Documentation

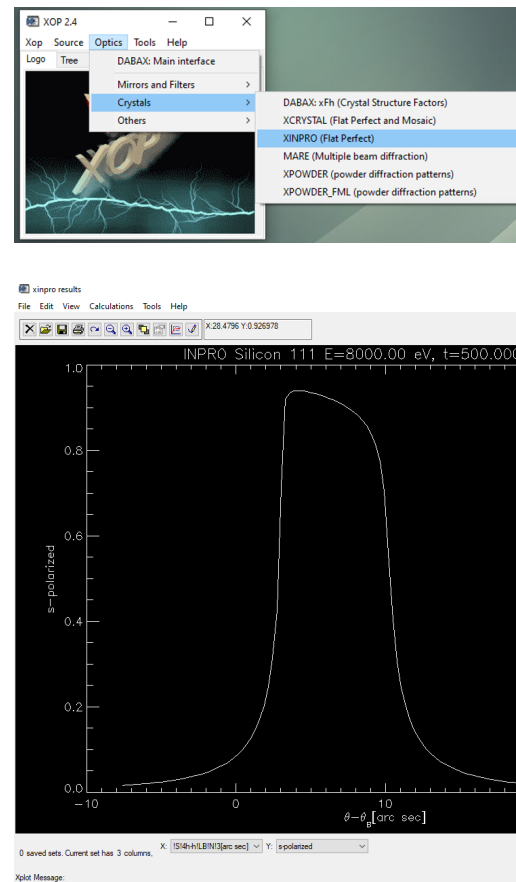
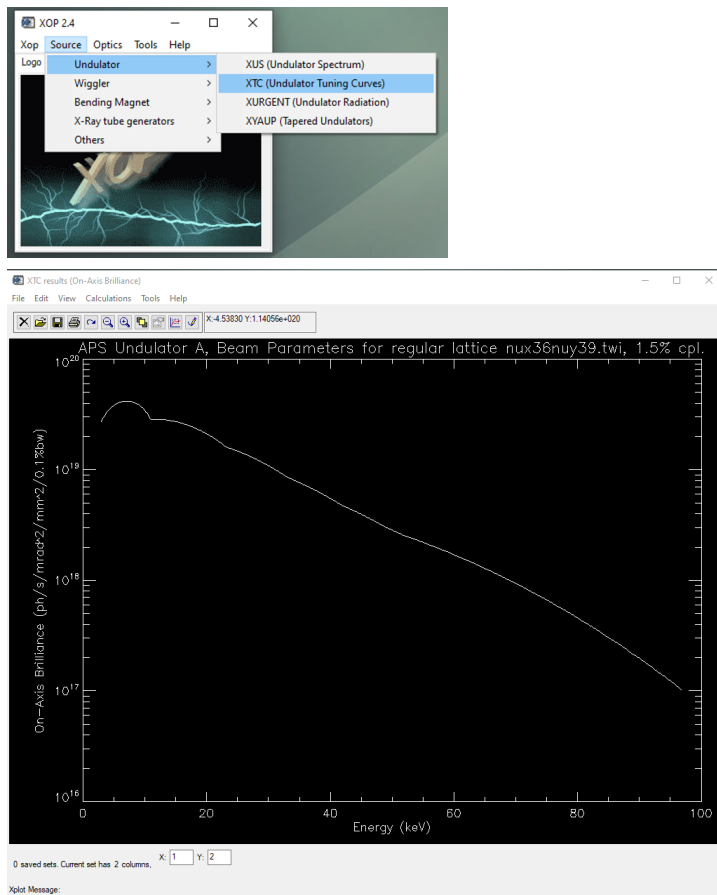
## XOP Extensions

- SHADOWVUI
  - Interface to the SHADOW ray-tracing code
- IMD
  - Multilayer software (Windt)
- TOPO
  - Surface topography (Windt)

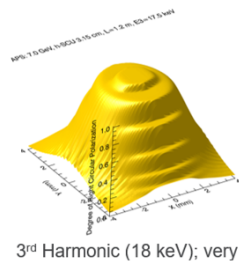
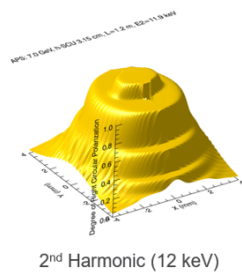
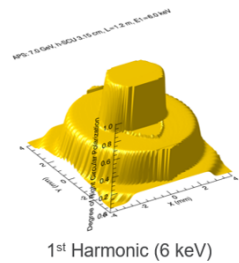
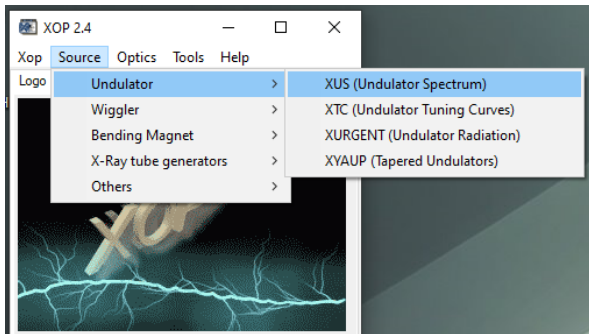


XPLOT

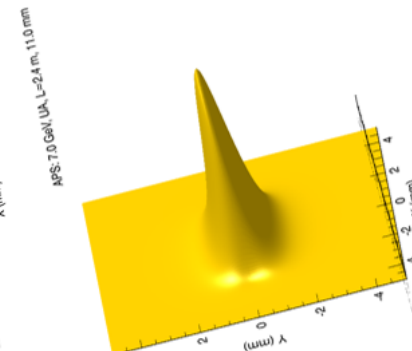
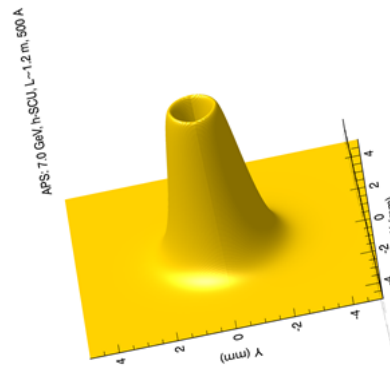
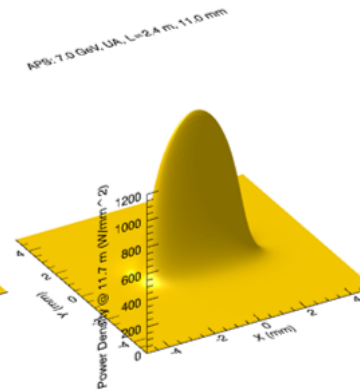
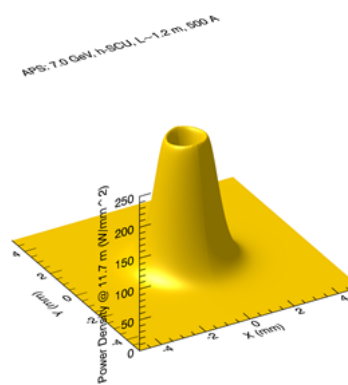
# XOP Examples – XTC and XINPRO



# XOP Examples – XUS




- $K_x=K_y=1.20$
- Distance 26.5 m
- General appearance correct – sharp edges not



## Current XOP Distribution v2.4 (2014)

- Used worldwide by synchrotron radiation facilities (and many others) and has been crucial for beamline designers and users for over a decade. The current version runs on Unix, Linux, Mac OS X, and Windows.
- The graphical user interface and many modules of the code are written in IDL, which is subject to U.S. Export Control and is categorized under Export Control Classification Number (ECCN) 5D002 (as of IDL v8.0). As such, it can only be distributed to users who have completed and submitted an application that is approved by the Argonne's Export Control process.
- Licensed since April 2015 with 2,029 application requests to date (10% denied)
- Embedded IDL license with IDL v8.3 good thru September 20, 2021 (no additional embedding requests planned)
- Replaced by the **OASYS** software, which contains some of the functionalities (codes) in XOP but with enhancements and new codes for different applications

# XOP Request for Downloads



Software Download for XOP v2.4 and Future Releases

Software Description

XOP (X-ray Oriented Programs) is a widget-based computer program used as a common front-end interface of codes of interest to the synchrotron radiation community. It provides codes formodeling of x-ray sources (e.g., synchrotron radiation sources, such as undulators and wigglers), characteristics of optical elements(mirror, filters, crystals, multilayers, etc.), and multipurpose data visualizations and analyses.

Instructions

New users please select the "Apply" button and fill out the application form.  
Authorized users please select the "Login" button and use your credentials to login.  
After Export Control Review you will be notified by e-mail how to use the "Authorized User Login."

Terms of Use

The software's intended use is to calculate radiation properties of x-ray sources and their propagation through optical elements.This software is subject to U.S. Export Control because it uses the Interactive Data Language (IDL) from Exelis Visual, and it is categorized under Export Control Classification Number (ECCN) 5D002. The software applicant agrees that the software and documentation will not be shipped, transferred or exported into any country, or used in any manner prohibited by U.S. export laws as detailed herein.

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The applicant needs to accept these terms on the XOP Software Download Application Form.

Start a New Application

Apply

Authorized User Login

Login

- <https://beam.aps.anl.gov/apps/xop/>



## References

- Manuel Sánchez del Río and Roger J. Dejus "XOP v2.4: recent developments of the x-ray optics software toolkit", Proc. SPIE 8141, Advances in Computational Methods for X-Ray Optics II, 814115 (23 September 2011); <https://doi.org/10.1117/12.893911>
- <https://www.aps.anl.gov/Science/Scientific-Software>
- <https://beam.aps.anl.gov/apps/xop/>
- [srio@esrf.fr](mailto:srio@esrf.fr) or [srio@lbl.gov](mailto:srio@lbl.gov)
- [dejus@anl.gov](mailto:dejus@anl.gov)

# **XOP SUCCESSFUL AND APPRECIATED 25 YEARS DOWNLOAD REQUESTS CONTINUES REPLACED BY THE NEW OASYS SOFTWARE**



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QUESTIONS?



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